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Client Reference: P-1695.000-US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of:
CASSANDRA M OWEN et al.

Confirmation Number: 7571

Application No.: 10/660,646

Group Art Unit: 1756

Filed: September 12, 2003

Examiner: Unknown

Title: ADAPTIVE THERMAL CONTROL OF LITHOGRAPHIC CHEMICAL PROCESSES

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

* * * *

REQUEST FOR CORRECTED FILING RECEIPT

Attached is a copy of the official filing receipt from the PTO in the above application for which issuance of a corrected filing receipt is respectfully requested. There is an error with respect to the following data which is incorrectly entered.

Error in

Applicant's Name

Correct data

Stephan Ewald Sinkwitz

Respectfully submitted,

PILLSBURY WINTHROP LLP



E. Rico HERNANDEZ
Reg. No. 47641
Tel. No. (703) 905-2000
Fax No. (703) 905-2500

Date: December 22, 2003

P.O. Box 10500
McLean, VA 22102
Customer Number: 00909



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APPL NO.	FILING OR 371 (C) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/660,646	09/12/2003	1756	906 O I P E JC114	081468-0304252	4	24	4

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 PILLSBURY WINTHROP, LLP
 P.O. BOX 10500
 MCLEAN, VA 22102



CONFIRMATION NO. 7571

FILING RECEIPT



OC000000011425900

Date Mailed: 12/05/2003

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Cassandra M Owen, Chandler, AZ;
 Wim T Tel, Helmond, NETHERLANDS;
 Stephan Ewald Sinkwitz, Solingen, GERMANY;

Assignment For Published Patent Application

ASML NETHERLANDS B.V., La Veldhoven, NETHERLANDS;

Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted: 12/04/2003

Projected Publication Date: 03/17/2005

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Early Publication Request: No

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By

Title

Adaptive thermal control of lithographic chemical processes

Preliminary Class

430

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